Sheet 1 of 1

U.S. Department of Commerce, Patent and Trademark Office					Atty Docket No. 11582 M-10088 US		Serial No		
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT						Applicant(s)		UNASSIGNE	
						Rand David Dannenberg			
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F		1 5	U.S. P	atent Documents		r	T:11: T	D-4-	
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing I		
(N	AA	5,047,131	Sep. 10, 1991	Wolfe et al.					
-0 -1	AB	5,113,109	May 12, 1992	Kawakatsu et al.					
	AC	5,814,195	Sep. 29, 1998	Lehan et al.					
m	AD	6,114,256	Sep. 5, 2000	Bachli et al.					
	AE								
	AF								
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-	AH							-	
	AI								
	AJ								
	AK								
			Foreign	Patent Documents		1	1	>	
							Translatio		
		Document	Date	Country	Class	Subclass	Yes	N	
(n_	AL	WO 96/34124	Oct. 31, 1996	PCT - WIPO					
	AM					·			
	AN							1	
	-l	OTHER	ART (Including A	uthor, Title, Date, Perti	inent Pages, E	tc.)] >	l	
Co	AO			Silver-Based Low Emisember 1989, pps. 43-53		g on Glass," So	lar Energy		
	AP	Szczybowski, J. et al., "Temperable Low Emissivity Coating Based on Twin Magnetron Sputtered TiO ₂ and Si ₃ N ₄ Layers," 1999 Society of Vacuum Coaters - 505/856-7188, pps. 141-146							
	AQ	Kacsich, T. et al. 30, 1999, pps. 1-		in Ti ₃₄ Si ₂₃ N ₄₃ Oxidat	ion," <u>Thin So</u> l	lid Films, Vol.	349, Nos. 1-3	3, Jul	
	AR			of Ti ₃₄ Si ₂₃ N ₄₃ Thin Fil I, Nos. 2-3, 21, Februar			nealing," <u>Sur</u>	rface	
b									
xaminer		8	Date Considere	d Am. L 30	2008				

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